Abstract—We present the effectiveness and competitiveness of a discontinuous Galerkin (DG) scheme applied to deterministic computations of the transients for the Boltzmann-Poisson (BP) system describing electron transport in semiconductor devices. In particular, we show that the scheme can maintain reasonable accuracy even with rather coarse meshes, hence providing a good alternative to the traditional DSMC solvers. Comparative studies for one-dimensional devices and simulations on a 2D double gate MOSFET are provided.

I. INTRODUCTION

In modern electronic devices the scale length of individual components becomes comparable with the distance between successive carrier interactions with the crystal. A consistent statistical description of the dynamics of carriers is essential for a deeper understanding of the observed transport properties. For this purpose the semi-classical Boltzmann-Poisson system is used and given by

$$\frac{\partial f}{\partial t} + \frac{1}{\hbar} \nabla_x \cdot (\varepsilon \, \nabla_x f) - \frac{q}{\hbar} E \cdot \nabla_k f = Q(f),$$  \hspace{1cm} (1)

$$\nabla_x \left[ \epsilon_r(x) E \right] = - \frac{q}{\varepsilon_0} \left[ \rho(t,x) - N_D(x) \right],$$  \hspace{1cm} (2)

which provides a general theoretical framework for modeling electron transport in electronic energy bands $\varepsilon = \varepsilon(k)$ associated to the crystal lattice. In Eq. (1), $f$ represents the electron probability density function (pdf) in phase space $k$ at the physical location $x$ and time $t$. $E$ is the electric field. $Q(f)$ denotes the collision operator, which describes electron-phonon interactions and $\varepsilon$ is the energy-band function. Physical constants $\hbar$ and $q$ are the Planck constant divided by $2\pi$ and the positive electric charge, respectively. In Eq. (2), $\varepsilon_0$ is the dielectric constant in the vacuum, $\epsilon_r(x)$ labels the relative dielectric function depending on the material, $\rho(t,x)$ is the electron density, and $N_D(x)$ is the doping. The term $Q(f)$ models the collisional integral given by a classical linear operator with scattering mechanisms satisfying the Fermi’s Golden rule accounting for acoustical (elastic) and absorption and emission (inelastic) transition rates (see [4] for a detailed description of the model).

The kinetic equation (1) is an equation in six dimensions (plus time if the model is not in steady state) for a truly 3-D device. Such high problem dimensionality and expected heavy computational cost have explained why the BP system is traditionally simulated by the Direct Simulation Monte Carlo (DSMC) methods [1].

After the pioneer work [6], in recent years, deterministic solvers to the BP system were proposed [2]–[5], [7]–[10]. These methods provide accurate results which, in general, agree well with those obtained from Monte Carlo (DSMC) simulations, often at a fractional computational time. Moreover, they can resolve transient details for the electron probability density function $f$, which are difficult to compute with DSMC simulators. The use of the discontinuous Galerkin (DG) method as we proposed in [4] for solving Eqs. (1)-(2) have considerable advantages over DSMC, including competitive computational cost for comparable resolution. We recall that the DG method is a finite element based approach that uses discontinuous piecewise polynomials as basis functions and relies on an adequate choice of numerical fluxes that handle effectively the interactions across element boundaries. They have been developed as an extraordinarily and highly adaptable computational tool which are stable and accurate for solving nonlinear hyperbolic conservation laws, nonlinear convection diffusion equations, etc. We refer to [4] for a detailed description of our scheme for solving Eqs. (1)-(2) and examples of applications of this DG scheme to 1D diode and 2D double gate MOSFET devices. A review on DG methods for BP system can be found in a recent review paper [11]. In the present paper, we will demonstrate the effectiveness and competitiveness of our computational approach in terms of maintaining accuracy for considerable coarse meshes and optimal computational times compared to DSMC solvers.

II. NUMERICAL RESULTS

Following [4] and previous related work referenced therein, we introduce a set of spherical coordinates using the wave vector $k = \kappa \sqrt{r(\mu, \sqrt{1 - \mu^2} \cos \varphi, \sqrt{1 - \mu^2} \sin \varphi)}$, with $r \geq 0$, $\mu \in [-1, 1]$ and $\varphi \in [-\pi, \pi]$, where $\kappa = \hbar^{-1} \sqrt{2m^* k_B T_L}$, $m^*$ is the effective electron mass, $k_B$ is the Boltzmann constant and $T_L$ the constant lattice temperature.
A. A one-dimensional device

First we will show the one-dimensional bulk device with an applied electric field of 10kV/cm to benchmark our scheme. We assume the Maxwellian distribution function at the initial time. The evolution of the mean velocity and mean energy is shown in Fig. 1 for a comparison between coarse and refined grids. The agreement is remarkably good given that the coarse mesh has only 8 cells in the \( \mu \)-direction. The table below describes the relative error of the quantities for different grids with respect to the most refined grid \( 80 \times 24 \). Here, \( N_r, N_\mu \) are the number of cells in \( r \) and \( \mu \) directions, respectively. Fig. 2 shows the distribution function as a function of \( r \) and \( \mu \) during the transient at time 0.4\( \mu \)s. Notice that the variable \( \phi \) is not considered for this problem due to the cylindrical symmetry.

<table>
<thead>
<tr>
<th>( N_r )</th>
<th>( N_\mu )</th>
<th>error in velocity</th>
<th>error in energy</th>
</tr>
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<tbody>
<tr>
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<td>16</td>
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<td>( 2.541e-05 )</td>
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<td>80</td>
<td>12</td>
<td>( 7.682e-03 )</td>
<td>( 4.423e-05 )</td>
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<td>( 5.557e-05 )</td>
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<td>24</td>
<td>( 1.660e-03 )</td>
<td>( 8.509e-04 )</td>
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<td>16</td>
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<td>8</td>
<td>( 2.296e-02 )</td>
<td>( 2.907e-03 )</td>
</tr>
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</table>

B. A two-dimensional double gate MOSFET

Here we consider a double gate MOSFET device as shown in Figure 3. The top and bottom shadowed region denotes the oxide-silicon region, whereas the rest is the silicon region. We will only need to compute for \( y > 0 \) because of the symmetry of the problem. The electric potential \( \Psi = 0 \) at source, \( \Psi = 1 \) at drain and \( \Psi = 0.5 \) at gate. The relative dielectric constant in the oxide-silicon region is \( \epsilon_r = 3.9 \), in the silicon region is \( \epsilon_r = 11.7 \). The doping profile has been specified as follows: \( N_D(x,y) = 1 \times 10^{17} \text{cm}^{-3} \) if \( x < 50 \text{nm} \) or \( x > 100 \text{nm} \), \( N_D(x,y) = 5 \times 10^{14} \text{cm}^{-3} \) in the channel \( 50 \text{nm} \leq x \leq 100 \text{nm} \). All numerical results are obtained with piecewise linear polynomials and second order TVD Runge-Kutta time stepping. We use a very coarse mesh, \( 24 \times 14 \) grid in space, 24 points in \( r \), 8 points in \( \mu \) and 6 points in \( \varphi \) in our calculation. In Figures 4 and 5, we show the macroscopic quantities for this device at equilibrium. In Figure 6, the transient state at \( t = 0.05 \mu \)s is given. We can identify some cells with negative energies. This numerical artifact is caused by a very coarse mesh we employed as well as the fact the gradient is really strong in this case. However, we want to remark that in [11], there are related discussions about the positivity of the solutions for BP systems. In general, if one uses only a piecewise constant approximation, then the solution will be positivity-preserving. However, for higher order approximations, this is no longer true and we observe it here in the transient states. The way to remove this numerical artifact without sacrificing accuracy is discussed in [11], [12] and are subjects of future study for our application.

III. Conclusion

In this paper, we demonstrate the performance of DG schemes for BP systems under coarse meshes. We show that the results are quite satisfactory for the calculation of steady states, and the computational cost is small even for five-dimensional calculations. However, for some transient states, we expect to see some numerical artifacts caused by using a high order approximation on a very coarse mesh. This will be the subject of our future study.

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References

Fig. 1. Velocity in cm/s (top) and Mean energy in eV (bottom) on refined (80x24) and coarse (20x8) grid versus time in ps.

Fig. 2. Dimensionless distribution function. Top: refined grid: 80x24; bottom: coarse grid: 20x8.

Fig. 3. Schematic representation of a 2D double gate MOSFET device.

Fig. 4. 2D double gate MOSFET at equilibrium. $t = 2\, \text{ps}$. From top to bottom: potential in $V$, x-component of electric field in $kV/cm$, y-component of electric field in $kV/cm$. 
Fig. 5. 2D double gate MOSFET at equilibrium. $t = 2\, ps$. From top to bottom: density in $cm^{-3}$, energy in $eV$, x-component of velocity in $cm/s$, y-component of velocity in $cm/s$.

Fig. 6. 2D double gate MOSFET at $t = 0.05\, ps$. From top to bottom: density in $cm^{-3}$, energy in $eV$, x-component of velocity in $cm/s$, y-component of velocity in $cm/s$. 